MAY 21 2007 W

Sir:

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	
Hiroko NAKAMURA et al.))
Application No.: 10/760,522 Filed: January 21, 2004 For: A METHOD FOR A PREDICTING A PATTERN SHAPE BY USING AN ACTUAL MEASURED DISSOLUTION RATE OF A PHOTOSENSITIVE RESIST (As amended)	Group Art Unit: 2123) Examiner: Dwin M. Craig) Confirmation No.: 1093
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450	

TRANSMITTAL LETTER

Enclosed is a reply to the Office Action of December 20, 2006. The item(s) checked below are appropriate:

Applicant hereby petitions for a two month extension of time to respond to the above Office Action.

The claims are calculated below:

	Claims Remaining After Amendment		Highest Number Previously Paid	Present Extra	Rate	Α	dditional Fee	
Total	31	-	32	0	x \$ 50	\$	0.00	
Indep.	13	-	12	0	x \$200		200.00	
First		0.00						
Subtotal								
Reduction by ½ if small entity								
TOTAL								

Dow

In re Application No.: 10/760,522 Attorney Docket No. 03180.0350-00

	A fee of \$200.00 to co enclosed.	ver the cost of the	e addit	ional claims	added by th	is reply is		
	A fee of \$ to cove	r		is enclosed.				
\boxtimes	Please charge the \$65 additional claims fees)				petition fees	s and \$200.00 fo		
Please grant any extensions of time required to enter this response and charge any additional required fees to Deposit Account 06-0916.								
Dated:	May 21, 2007	By	: 6	tichard V. Bu	<i>' [W]_{6 . :}</i> Irgujian '44	53,232		